

Coating 136442

Magnetron sputtered system

$HR(0^\circ, 620-1150\text{nm}) > 99.8\% + R(0^\circ, 532\text{nm}) < 5\%$

GDD optimiert

small peaks down to 99.7% possible

fig. 1 reflection, 0°

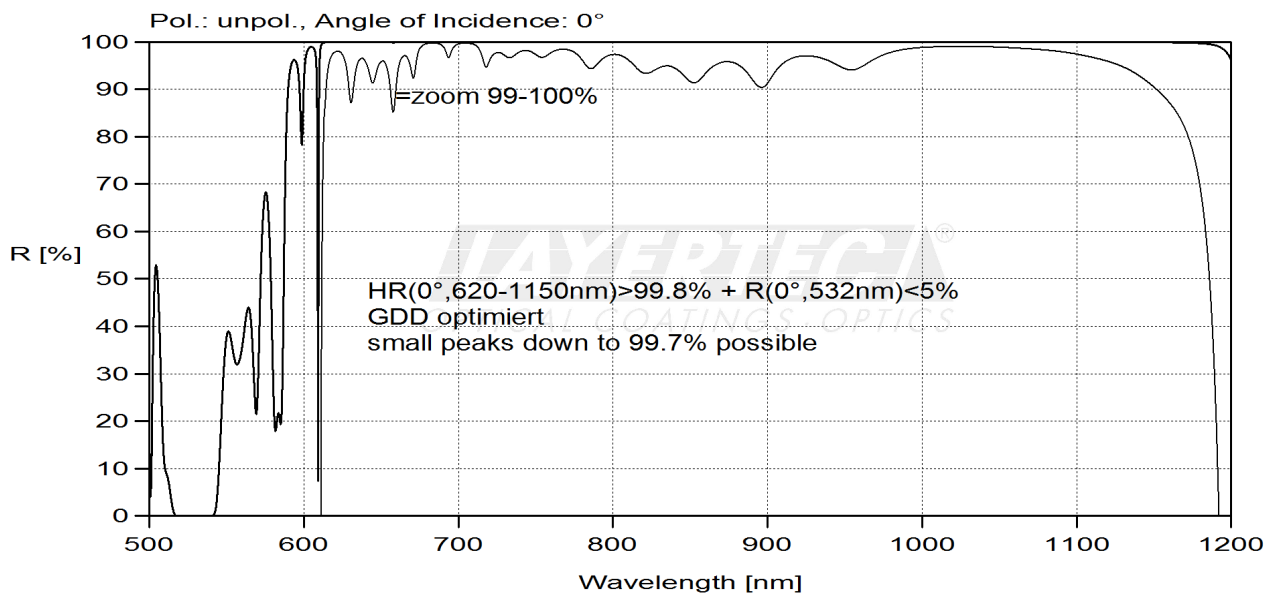


fig. 1 GDD reflection, 0°

